Helium effects on Tungsten surface morphology and Deuterium retention

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Introduction

Recent experimental results on low energy He induced morphologies (nano-structure) and He effect on D retention are reviewed.

Outline of this talk

- Formation of nano-structures in linear plasma devices
- Formation of nano-structures in magnetic confinement devices
- Erosion and arcing of nano-structures
- Simultaneous He irradiation effect on D retention
- Summary

Low energy* He effects on W

☐ High temperature

- Large He bubbles formation with recrystallization
- Degradation of mechanical and thermal properties

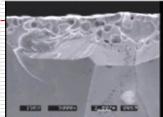
■ Medium temperature

- Nano-structure (fuzz) formation
- Porous structure
- Low thermal conductivity

□ Low temperature (< ~900 K)</p>

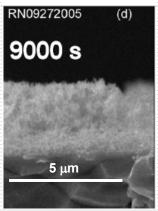
- Small He bubble formation (a few nm)
- Degradation of mechanical and thermal properties
- Affects D/T retention

W1 ≈30 eV



NAGDIS (Nagoya Univ.)

T ~ 2,100 K

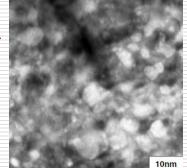




PISCES (UCSD) NAGDIS (Nagoya U.)

 $T \sim 1,120 \text{ K}$ $T \sim 1,400 \text{ K}$





PISCES (UCSD)

T ≤ **773 K**

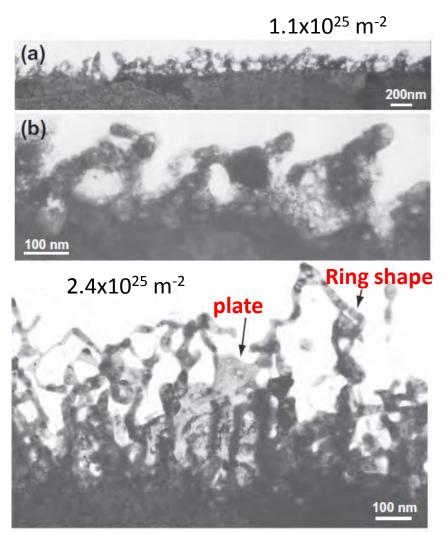
Low energy* :around 100 eV or less

Formation of nano-structures in linear plasma devices

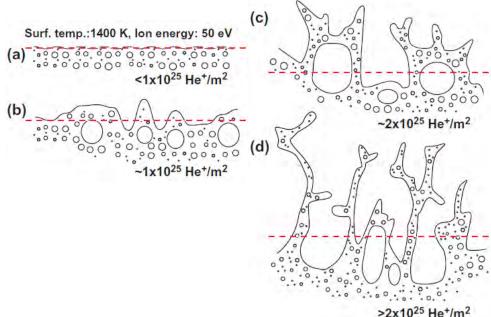
- ☐ How are they formed?
 - Formation mechanism
 - Formation Conditions

TEM observation of nanostructured tungsten: formation mechanism

NAGDIS



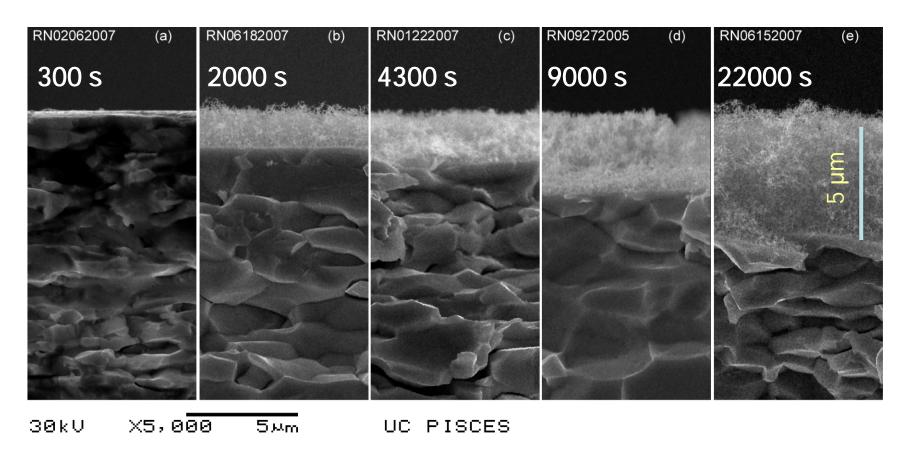
He irradiated W in NAGDIS-II at 1400 K and 50 eV.



- •Many nanometer sized helium bubbles are formed on the surface by the exposure to helium plasmas.
 •With the help of an active surface diffusion, pinholes, dips, and protrusions are formed on the surface.
 •The shape of structure becomes complicated ones such as plain-like or pillar-like structures.
 - S. Kajita, N. Yoshida et al. JNM **418** (2011) 152–158

At 1120 K, nano-structured layer thickness increases with He plasma exposure time.

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Consistent He plasma exposures: T_s = 1120 K, Γ_{He+} = 4–6 × 10²² m⁻²s⁻¹, E_{ion} ~ 60 eV

Layer growth follows kinetics that are controlled by a diffusion like process.

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- Observed $t^{1/2}$ proportionality.
- The thickness of the nanostructured layer, *d*, agrees well with

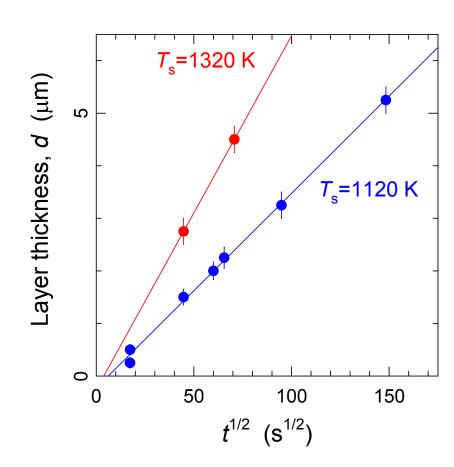
$$d=(2Dt)^{1/2}$$
,

with,

$$D_{1120 \text{ K}} = 6.6 \pm 0.4 \times 10^{-16} \text{ m}^2\text{s}^{-1}$$

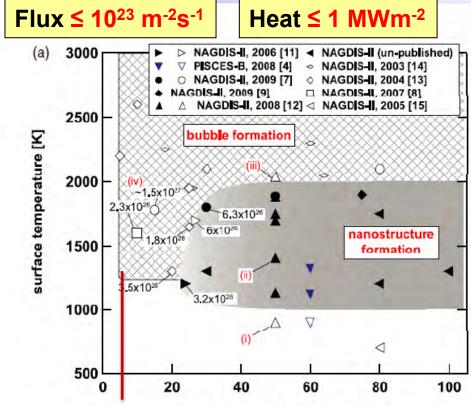
 $D_{1320 \text{ K}} = 2.0 \pm 0.5 \times 10^{-15} \text{ m}^2\text{s}^{-1}$

 Overall process is consistent with an activation energy of ~0.7 eV.



NAGDIS-II and PISCES

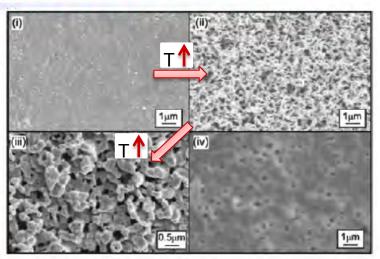
Summary of W fuzz formation condition



Surface barrier energy incident ion energy [V]

Surface Temp: 1000 K < T < 2000 K
Ion Incident Energy>20 eV

S. Kajita et al., Nucl. Fusion 49 (2009) 095005

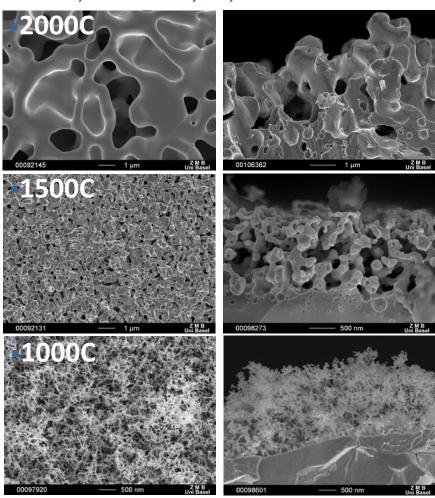


- Closed markers
 with nanostructure
 open markers
 without nanostructure
- [4] M. Baldwin NF (2008).
- [7] W. Sakaguchi JNM (2009)
- [8] S. Kajita, NF (2007).
- [9] S. Kajita, NF (2009).
- [11] S. Kajita, J. Appl. Phys. (2006).
- [12] W. Sakaguchi, Proc. 18th Int. Toki Conf. (2008).
- [13] D. Nishijima, JNM (2004).
- [14] D. Nishijima, JNM (2003).
- [15] D. Nishijima, NF (2005).

Effect of surface temperature

W target

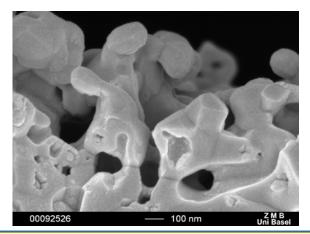
 $1000 \, s, \, 5x10^{26} \, He^+/m^2, \, 50 \, eV \, He^+$



Pilot-PSI: $\sim 5 \times 10^{23} \text{ m}^{-2}\text{s}^{-1} (\sim 4 \text{ MW/m}^2)$

Closer to divertor flux condition

- Low energy helium ion exposure at high surface temperatures induce formation of near surface voids/bubbles
- □ Correlation between bubble size and helium-induced nanostructure scale
- □ Coalescence of He bubbles and swelling of tungsten surface





Similar mechanism for Mo and W

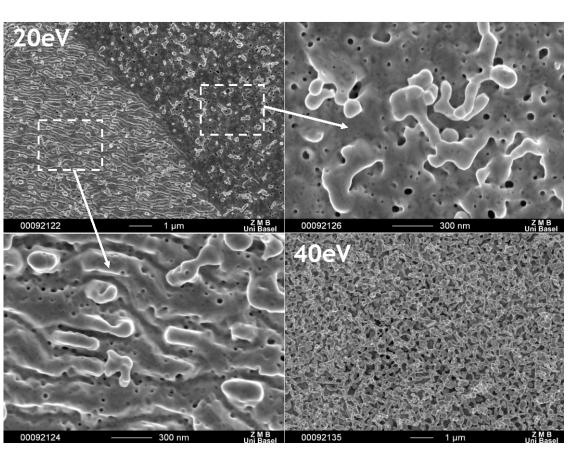




Effect of ion energy for W

W target, low flux region

1000 C, 500 s, $2x10^{26} He^+/m^2$

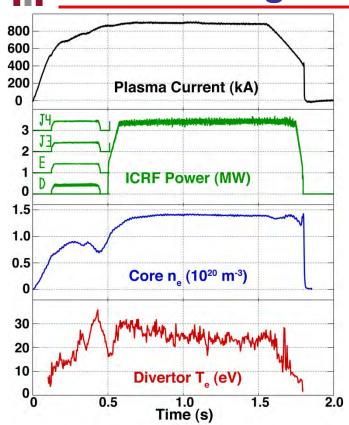


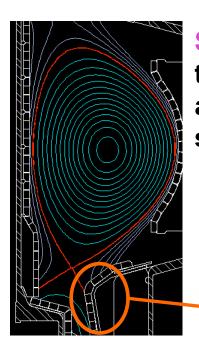
- □ Ion energy has a strong effect on the nano-structure formation kinetics
- □ Surface modification is strongly dependent on the grain orientation at the beginning of the process
- Once the structure has developed, there is no trace of these initial differences

Formation of nano-structures in magnetic confinement devices

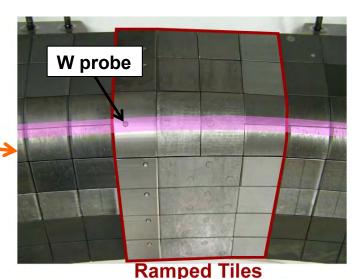
- □ Are nano-structures formed in magnetic confinement devices?
 - Different ion irradiation conditions from linear plasmas
 - Oblique incidence of impinging ions
 - Ion energy distribution
 - Mixed ion effects (enhanced erosion, deposition, etc.)
 - □ D/T, He, wall materials, cooling gas etc.
 - Reactor relevant high heat flux condition (~10 MW/m² or more)

Alcator C-Mod Helium plasmas produced necessary plasma conditions for nanotendril growth at the outer strikepoint





Strike point run on the nose tiles to reduce flux expansion allowing for higher local surface temperatures.



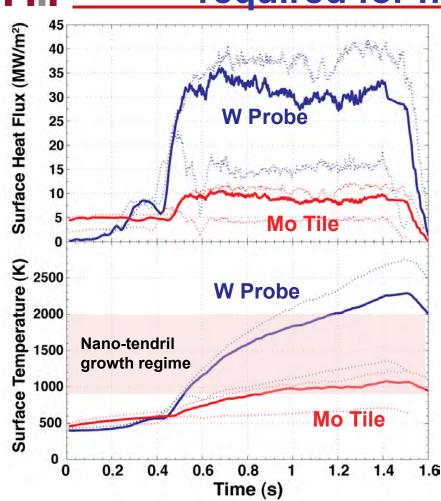
14 repeated L-mode discharges

• $T_{e,divertor}$ 20-25 eV, $q_{||} > 0.2$ GW/m²

→ 13-15 s of total exposure at appropriate growth conditions

Prepared by : G. Wright (MIT)

Both the tungsten probe and surrounding Mo tile surfaces reached temperatures required for nano-tendril growth



W probe ramped ~11° into parallel heat flux and is electrically/thermally isolated.

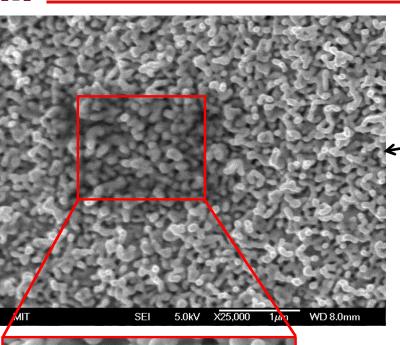
Mo tiles are ramped ~2° into parallel heat flux and grounded.

→ W probe intercepts more parallel heat flux and reaches *much higher* surface temperatures than the surrounding Mo surfaces.

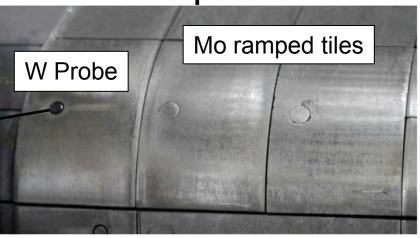
Solid lines = Heat flux (or temperature) for discharge which is the 14-shot median

Dotted lines = Heat flux (or temperature) for discharges having the 14-shot maximum or minimum

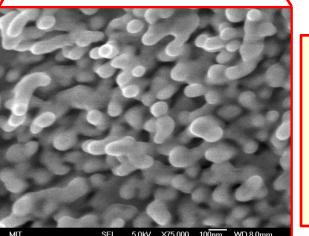
Nano-tendrils are fully formed on surface of the tungsten probe exposed to heat fluxes of 30-40 MW/m²



After exposure



Lack of nano-tendrils on Mo surfaces (still under investigation):

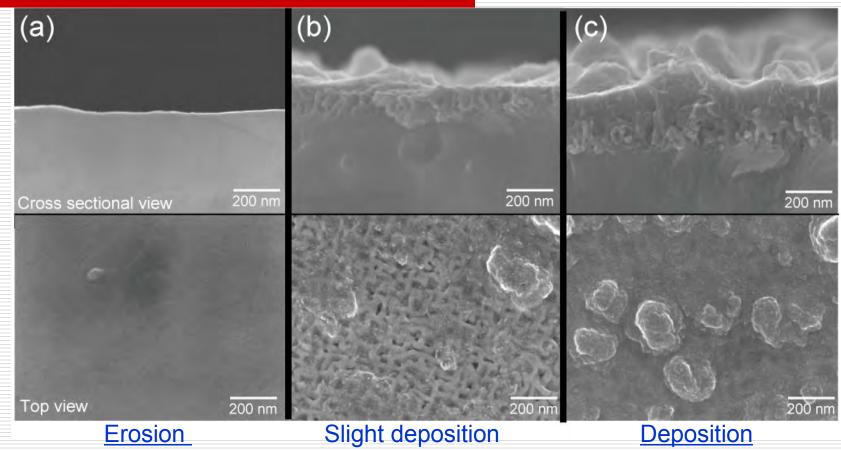


Thickness of individual tendril is 50-100 nm, which is thicker than tendrils grown in linear devices (20-30 nm)

- Different sputtering thresholds
- Different temperature evolution
- Possible impurity coating (boron?)
 on ramped Mo tiles

Prepared by : G. Wright (MIT)

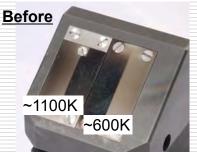
Pre-made fuzz exposure to D/He TEXTOR plasma

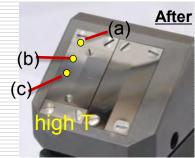


Under TEXTOR D/He mixed plasma: Only <u>erosion</u> and C <u>deposition</u> area No evidence of fuzz growth

Probably due to high C concentration

Y. Ueda et al., J. Nucl. Mater. (2011) in print.



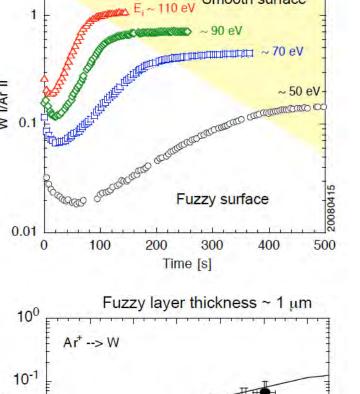


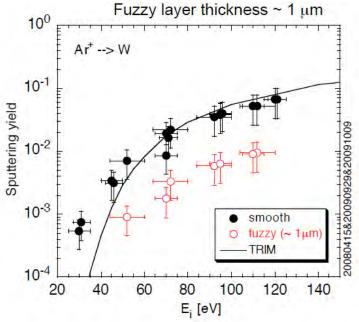
Erosion and arcing of nanostructures

- How do they behave in edge plasmas?
 - Sputtering erosion
 - Thermal annealing without He irradiation
 - Response to pulsed heat/particles
 - Unipolar arcing (enhanced erosion)

W fuzz has lower physical sputtering yield than smooth W.

- Fuzz produced on W by He plasma exposure over 800 s at 1150 K, $E_i \sim 90$ eV.
- Switch to He/Ar plasma at t = 0 s, & measure time evolution of W I emission in front of W target.
- $Y_{smooth}(Ar^+\rightarrow W) \sim 0.05 @ E_i \sim 110 eV$, by mass loss. (Agrees w/ TRIM).
- $Y_{fuzzv} = (0.05 / WI/ArII_{110 eV, smooth}) x WI/ArII$
- Why is the sputtering yield reduced?
 - Porosity? Internal bubble?
 - Not well understood.

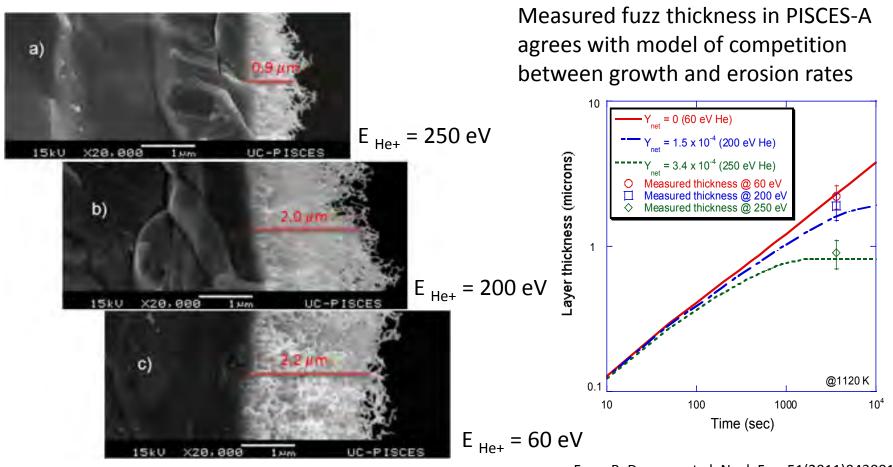




From D. Nishijima et al., PSI-19 in press JNM.

Erosion of fuzzy surface leads to an equilibrium layer thickness where erosion = growth rate

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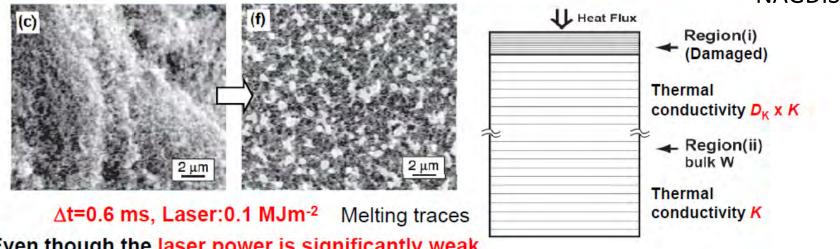


From R. Doerner et al. Nucl. Fus. 51(2011)043001

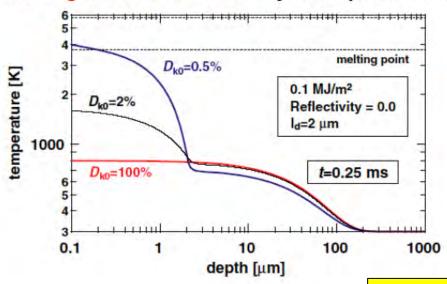
ELM-like pulsed heat effect

Nanostructure melts even if the power is very low

NAGDIS



Even though the laser power is significantly weak, melting traces are formed by laser pulse irradiation.



- Thermal conductivity decreases effectively by more than two orders of magnitude.
- •Fiberform nanostructure is considerably weak for pulsed heat load, though the material has durability to continuous heat load.

S. Kajita, NF(2007)

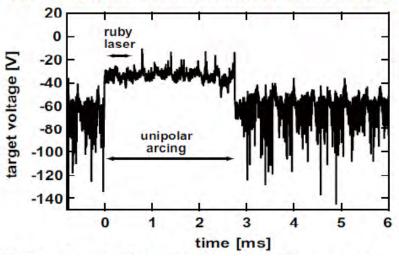
W is released over certain pulse energy

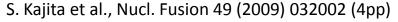
Prompt ignition of unipolar arc: Revival of arcing issue in fusion?!

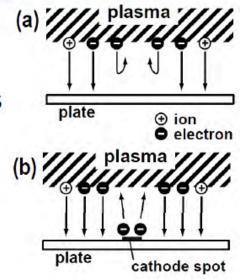
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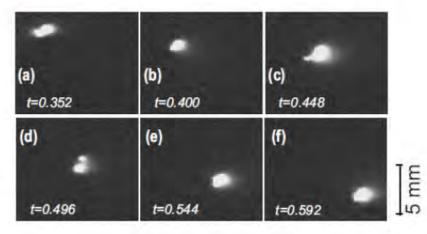
Arcing ignited at the floating potential.
 Unipolar arcing is the mechanism of the arcing in fusion devices; however, there is no report in steady state plasma in laboratory experiments.

•ELMs could trigger the unipolar arcing with ease for helium irradiated W.









Premade W fuzz samples survive plasma gun heat and particle loads

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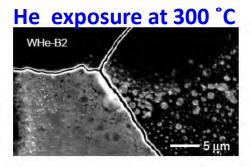


Fig. 3. W surface cracking on WHe-B2 after 10 shots with $\sim 0.5 \text{ MJ/m}^2$ per shot.

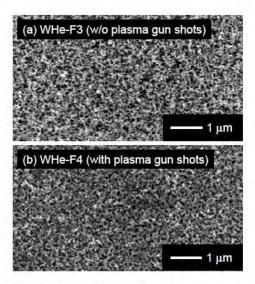
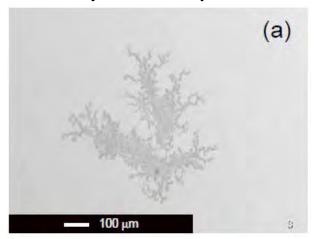
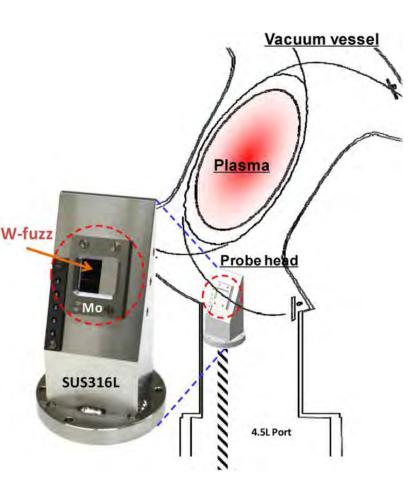


Fig. 4. SEM images of fuzzy W surfaces ($L \sim 3 \mu m$). (a) WHe-F3: without plasma gun shots. (b) WHe-F4: after 10 plasma gun shots with $\sim 0.7 \text{ MJ/m}^2$ per shot.

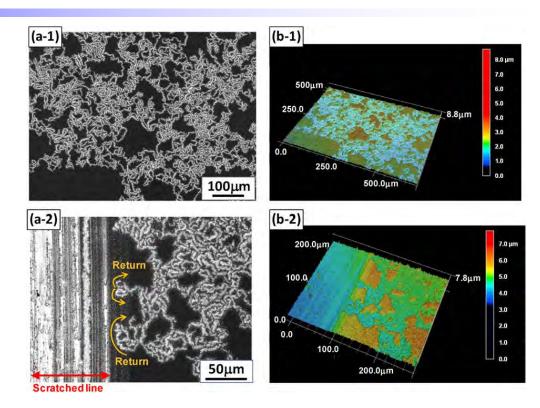
- Fuzzy W samples do not crack after repeated ~0.7 MJ/m² shots
- Larger surface area may dissipate heat load or nano-castelation effect
- However, arc tracks are observed only on fuzzy W samples



Demonstration of arcing on fuzz-W in LHD



- -Nanostructured W formed in the NAGDIS-II was installed in LHD.
- -Arcing was initiated by the exposure to the LHD plasma, the duration of which was 2s.



- -Since the magnetic field direction was almost normal to the target, the motion was Brownian-like.
- -This results strongly suggest that arcing can be easily initiated when the nanostructure is formed on the surface.

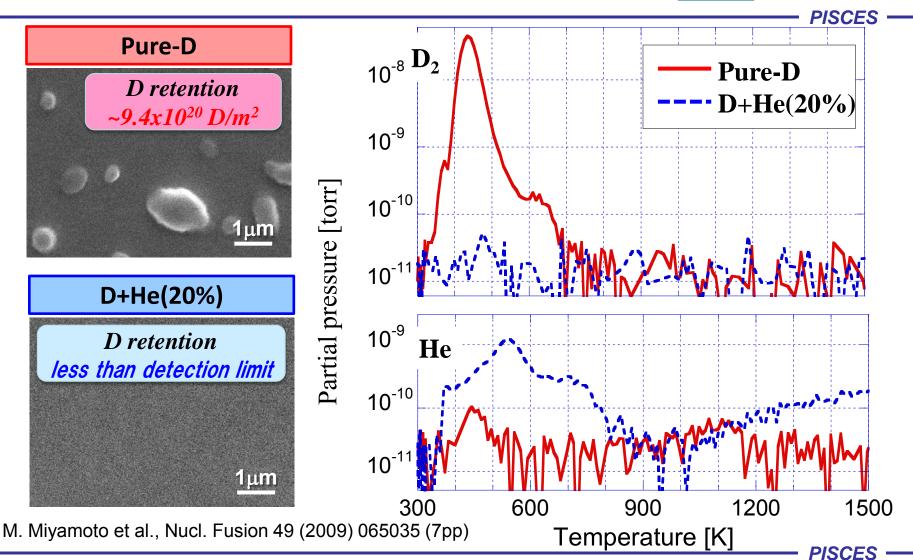
M. Tokitani *et al.* Nucl. Fusion 51 (2011) 102001.

Simultaneous He irradiation effect on <u>D retention</u>

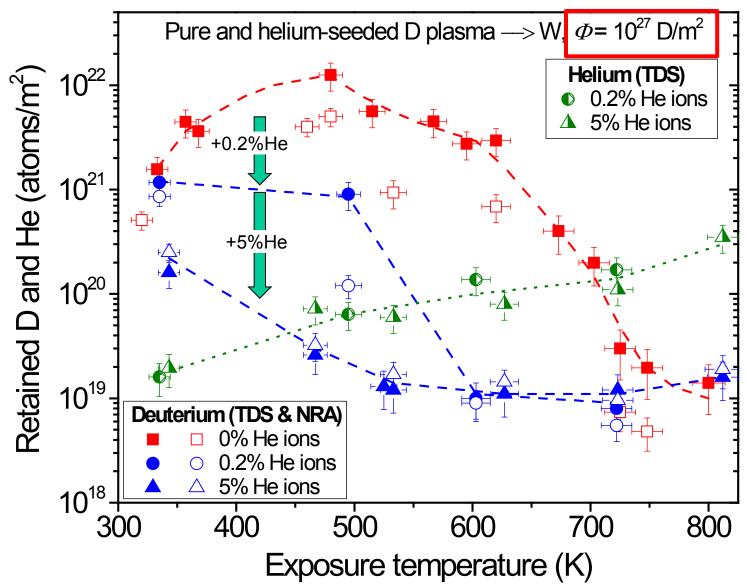
☐ How do He ions affect D/T retention in tungsten?

Suppression of D retention by He

■SR-W, 5x10²⁵ D/m², @<u>573K</u>

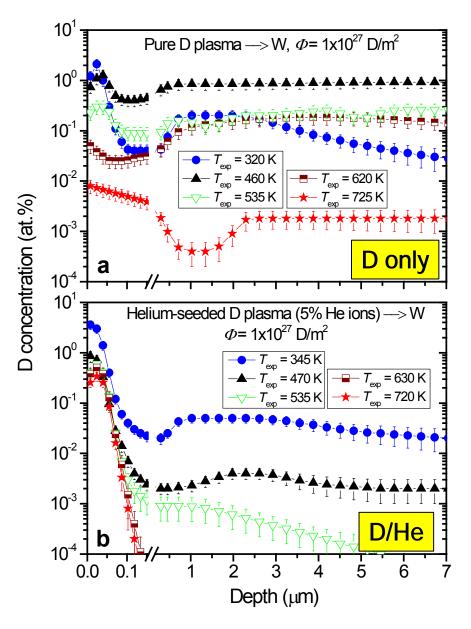


Deuterium retention in re-crystallized W exposed to pure and helium-seeded D plasmas, $\Phi = 10^{27} \text{ D/m}^2$



Prepared by V. Alimov

Deuterium depth profiles in re-crystallized W exposed to pure 27 and helium-seeded D plasmas, $\Phi = 10^{27} \text{ D/m}^2$



After exposure to pure D plasma at $T_{\rm exp}$ = 320-620 K, deuterium depth profiles are characterized by high D concentration (0.1-1 at.%) at depths of up to several micrometers.

Seeding of helium into the D plasma significantly reduces the D concentration in the sub-surface layer (1-7 micrometers).

The D concentration in the near-surface layer is higher than that for pure D plasma exposure.

Osaka University

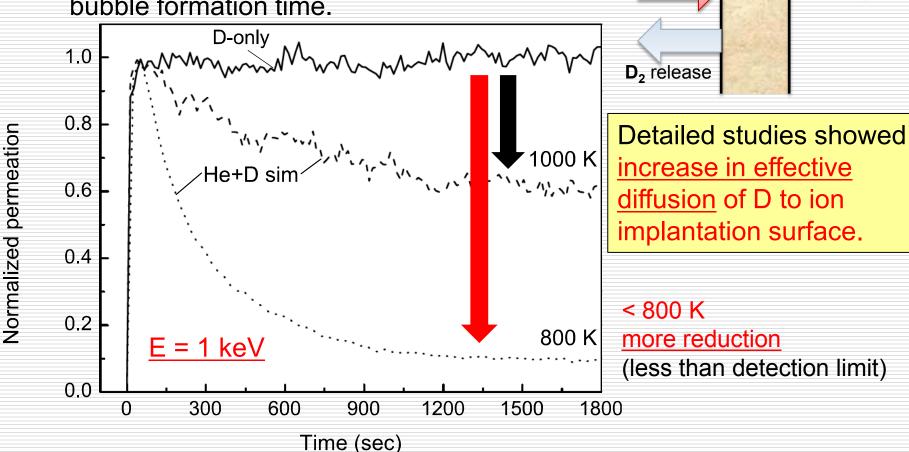
D Permeation

He/D mixed ion driven permeation

- □ Addition of He (2%) greatly reduces

 D/He

 W foil (30 µm)
- Saturation time almost corresponds to He bubble formation time.



H. T. Lee et al., J. Nucl. Mater. (2011) in print.

permeation flux.

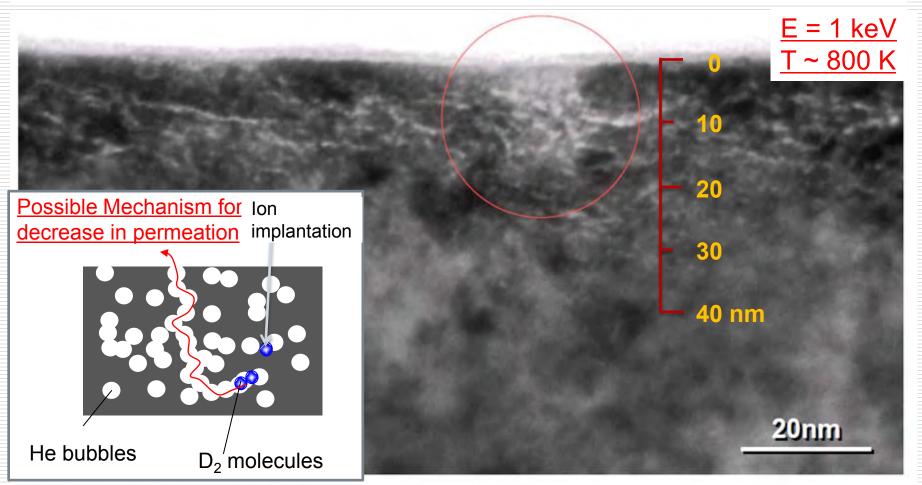
ICFRM15, Y. Ueda et al., October, 2011

Implantation

Enhanced D desorption by He bubble layer Osaka University



- He bubble layer was observed up to the depth of about 20 nm.
- Thickness of He bubble layer was larger than ion range (~10 nm).
- He bubbles are interconnected to form pores connected to the surface.



Summary

- □ Formation of nano-structures
 - Role of He bubbles on initial formation is understood.
 - Diffusion-like growth is observed.
 - Formation conditions (ion energy, temperature) are clarified.
 - Formation in a confinement device (Alcator C-Mod) was observed on W (but not on Mo).
- Erosion and arcing of nano-structure
 - Physical sputtering is lower than smooth surface.
 - Unipolar arcing is liable to occur in any high density plasmas.
 - Eases a pulsed heat effect such as cracking.
 - Thermally annealed at ~1400 K or more without He irradiation.
- ☐ He effects on D retention
 - Simultaneous He/D irradiation greatly reduces D retention and D influx.

More information is necessary to fully understand characteristics of nanostructure and He/D retention, but we already have a lot of knowledge to evaluate their impacts on fusion plasmas and lifetime of tungsten.